

APPLICATION NO.

10/618,874

23494

UNITED STATES PATENT AND TRADEMARK OFFICE

FILING DATE

07/14/2003

TEXAS INSTRUMENTS INCORPORATED

06/17/2004

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HA, NATHAN W

PAPER NUMBER

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FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
Mukul Saran	TI-30597.1	5871
	EXAMINER	

ART UNIT 2814

DATE MAILED: 06/17/2004

Please find below and/or attached an Office communication concerning this application or proceeding.

			如
•	Application No.	Applicant(s)	
Office Action Summary	10/618,874	SARAN, MUKUL	
	Examiner	Art Unit	
	Nathan W. Ha	2814	
The MAILING DATE of this communication Period for Reply	appears on the cover sheet w	th the correspondence address	
A SHORTENED STATUTORY PERIOD FOR RE THE MAILING DATE OF THIS COMMUNICATIO - Extensions of time may be available under the provisions of 37 CFF after SIX (6) MONTHS from the mailing date of this communication - If the period for reply specified above is less than thirty (30) days, a - If NO period for reply is specified above, the maximum statutory pe - Failure to reply within the set or extended period for reply will, by st Any reply received by the Office later than three months after the m earned patent term adjustment. See 37 CFR 1.704(b).	N. R 1.136(a). In no event, however, may a reply within the statutory minimum of thi riod will apply and will expire SIX (6) MOI atute, cause the application to become A	reply be timely filed ty (30) days will be considered timely. ITHS from the mailing date of this communication. BANDONED (35 U.S.C. § 133).	
Status			
1)⊠ Responsive to communication(s) filed on 4.	/1/04.		
•	This action is non-final.		
3) Since this application is in condition for allo	wance except for formal mat	ers, prosecution as to the merits is	
closed in accordance with the practice und	er <i>Ex par</i> te <i>Quayl</i> e, 1935 C.[). 11, 453 O.G. 213.	
Disposition of Claims			
4)⊠ Claim(s) 9-14 is/are pending in the applicat	tion.		
4a) Of the above claim(s) is/are with	drawn from consideration.		
5) Claim(s) is/are allowed.			
6)⊠ Claim(s) <u>9-14</u> is/are rejected.	•		
7) Claim(s) is/are objected to.			
8) Claim(s) are subject to restriction an	nd/or election requirement.		
Application Papers			
9)☐ The specification is objected to by the Exam	niner.		
10) The drawing(s) filed on is/are: a) ☐	accepted or b) objected to	by the Examiner.	
Applicant may not request that any objection to	the drawing(s) be held in abeya	nce. See 37 CFR 1.85(a).	
Replacement drawing sheet(s) including the cor	rrection is required if the drawing	(s) is objected to. See 37 CFR 1.121(d)).
11)☐ The oath or declaration is objected to by the	e Examiner. Note the attache	d Office Action or form PTO-152.	
Priority under 35 U.S.C. § 119	,		
 12) Acknowledgment is made of a claim for fore a) All b) Some * c) None of: 1. Certified copies of the priority documents. 2. Certified copies of the priority documents. 3. Copies of the certified copies of the papplication from the International But * See the attached detailed Office action for a 	nents have been received. nents have been received in A priority documents have beer reau (PCT Rule 17.2(a)).	application No received in this National Stage	
Attachment(s)			
1) Notice of References Cited (PTO-892)	• —	Summary (PTO-413)	
2) Notice of Draftsperson's Patent Drawing Review (PTO-948)	′	s)/Mail Date nformal Patent Application (PTO-152)	
 Information Disclosure Statement(s) (PTO-1449 or PTO/SE Paper No(s)/Mail Date 	6) Other:		

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DETAILED ACTION

Claim Rejections - 35 USC § 102

1. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.

2. Claims 9-13 are rejected under 35 U.S.C. 102(e) as being anticipated by Ning et al. (US 6,677,635, newly cited, hereinafter, Ning.)

In regard to claim 9, in fig.5, Ning discloses a method of forming an IC capacitor, comprising:

providing a silicon substrate, not shown, with a first dielectric film 11 containing at least one copper layer 10, see also, col. 4, lines 7-10;

forming a second dielectric layer 12 over the first dielectric layer and the copper layer wherein the second dielectric layer contacts the copper layer;

forming a first conductive layer 16 over the first dielectric layer wherein the first conductive layer contacts the electric layer, see fig.5; and

removing portion of the first conductive layer such that a portion of the second dielectric layer remains between the first conductive layer and the copper layer wherein these layers formed a capacitor structure. See col. 4, lines 1-10.

In regard to claim 10, Ning further discloses forming copper contacts to the first conductive layer, see fig.5; and

forming a second copper layer that electrically contacts the copper contacts.

In regard to claim 11, the first conductive layer suggested to be aluminum, see col. 4, lines 45-47.

In regard to claim 12, see fig.5, where the dielectric layer is formed using a least two dielectric films, including 15, for example.

In regard to claim 13, layer 12 may be considered as a barrier layer.

In regard to claim 14, the dielectric layer is made of silicon nitride. See col. 4, lines 15-17.

Response to Arguments

3. Applicant's arguments with respect to claims 9-14 have been considered but are moot in view of the new ground(s) of rejection.

Conclusion

4. **THIS ACTION IS MADE FINAL.** Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not

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mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the mailing date of this final action.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Nathan W. Ha whose telephone number is (571) 272-1707. The examiner can normally be reached on M-TH 8:00-7:00(EST).

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Wael Fahmy can be reached on (571) 272-1705. The fax phone number for the organization where this application or proceeding is assigned is (703) 872-9306.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703) 308-0956.

Nathan Ha June 12, 2004 Wael fahrung SPE 2814